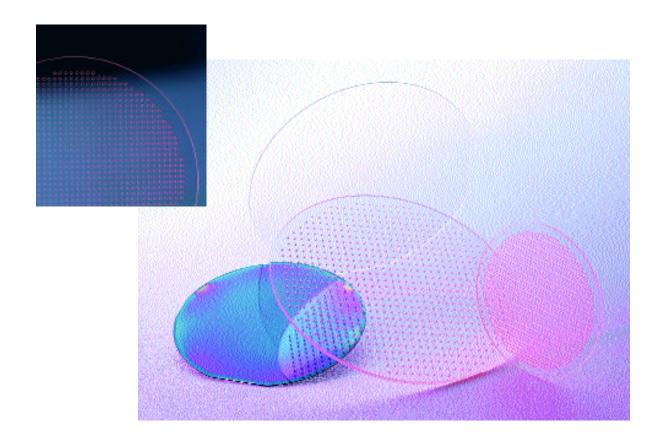
## **CORNING**

## **Glass Silicon Constraint Substrates**

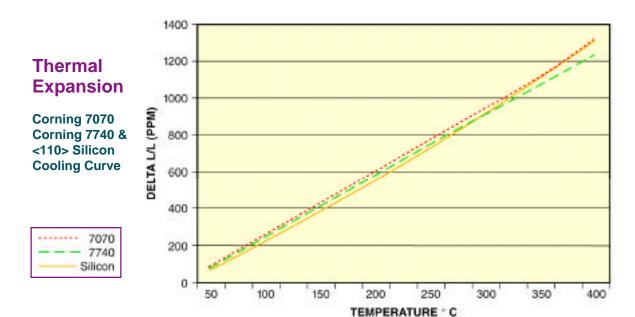


Corning supplies a variety of polished and machined glass wafers for use in the fast-growing MST/MEMS (Micro Systems Technology/Micro-Electrical-Mechanical Systems) technologies.

The substrates are produced using the *industry standard* Pyrex® (Corning code 7740) and other silicon thermal expansion matching glasses, such as Corning code 7070; coupled with innovative manufacturing techniques, world class measurement, and global sales and technical support.

## Materials: Pyrex® 7740 Borosilicate Glass 7070 Lithia Potash Borosilicate

Glass Properties:		7740	7070
Mechanical	Density (g•cm <sup>-3</sup> )	2.23	2.13
	Young Modulus (G Pa)	62.75	51.00
	Poisson Ratio	0.20	0.22
	CTE, 0-300°C (x10 <sup>-6</sup> •°C <sup>-1</sup> )	3.25	3.20
Viscosity	Working Point (°C) 10 <sup>4</sup> Poise	1252	1068
	Softening Point (°C) 10 <sup>7.6</sup> Poise	821	n/a
	Annealing Point (°C) 10 <sup>13</sup> Poise	560	496
	Strain Point (°C) 10 <sup>14</sup> Poise	510	456
Electrical	Log volume resistivity ( cm): 250°C, 350°C	6.1, 4.6	11.2, 9.1
	Dielectric Constant, 20°C, 1MHz	4.6	4.1
	Loss Tangent, 20°C, 1 MHz (%)	0.5	0.06



Standard Diameters: SEMI standard wafer diameters:

75.0mm +/- 0.5mm 100.0mm +/- 0.5mm 125.0mm +/- 0.5mm 150.0mm +/- 0.5mm

Other shapes and sizes (for example, rectangles) will be quoted upon request

Drilled or machined wafers are also available upon request

Standard Thickness: 1.0mm +/- 0.025mm

0.5mm +/- 0.025mm

Orientation Flats: SEMI standard flats will be quoted upon request

Edge Beveling: Standard for 1.0 and 0.5mm thick wafers

Warp: Less than 20 microns

**Total Thickness** 

Variation (TTV): Less than 20 microns

**Surface Finish:** Both sides polished to Ra < 15Å typical

Inspected under intensive light (approximately 1500 lux) for scratches and cracks;

top and bottom surfaces - no faults found

Inclusions: No inclusions greater than 0.3mm diameter allowed

No open inclusions or bubbles

Edge Chips: No chips greater than 1.0mm diameter

Packaging: "Coin Stack" canister, foam packed at each end

Wafers interleaved with lint free spacers

25 wafers per canister

Wafer cassettes or carriers are available at additional cost

**Hole Drilling Guidelines:** 

(Typical)

Feature location +/- 0.05mm Minimum hole diameter 0.25mm

Hole diameter tolerance +/- 0.05mm Matrix hole pitch, minimum 1.5 x hole diameter

CORNING

**Specialty Lighting & Materials** 

Houghton Park C-8 Corning, NY 14831 Phone: 607-974-9000 Fax: 607-974-7618 E-mail: waferglass@corning.com Internet: www.slam.corning.com

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